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DATE MAILED: 09/23/2004

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/707,754	01/09/2004	Jochen Beintner	FIS920030312	FIS920030312 1753	
29505	7590 09/23/2004		EXAMINER		
DELIO & PETERSON, LLC			ERDEM, FAZLI		
121 WHITNEY AVENUE NEW HAVEN, CT 06510			ART UNIT	PAPER NUMBER	
•	,		2826	2826	

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary		Application No.	Apı	plicant(s)			
		10/707,754	BE	BEINTNER ET AL.			
		Examiner	Art	Unit			
		Fazli Erdem	/ 282	26			
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.  - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.  - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).							
Status							
1)🛛	Responsive to communication(s) filed on 2	26 August 2004.					
2a)□							
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposit	ion of Claims						
5)⊠ 6)⊠ 7)⊠	4)  Claim(s) 1-31 is/are pending in the application. 4a) Of the above claim(s) 15-31 is/are withdrawn from consideration.  5)  Claim(s) 10-14 is/are allowed.  6)  Claim(s) 1-3,8 and 9 is/are rejected.  7)  Claim(s) 4-7 is/are objected to.  8)  Claim(s) are subject to restriction and/or election requirement.						
Applicat	ion Papers						
9)[	The specification is objected to by the Exan	niner.					
10)	10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.						
	Applicant may not request that any objection to	the drawing(s) be held	in abeyance. See 37 (	CFR 1.85(a).			
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).  11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority (	under 35 U.S.C. § 119						
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>							
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  4) Interview Summary (PTO-413)  Paper No(s)/Mail Date							
1 Notice of Dratisperson's Patent Drawing Review (PTO-946)  3 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)  Paper No(s)/Mail Date 01/09/2004.  5 Notice of Informal Patent Application (PTO-152)  6 □ Other:							

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### **DETAILED ACTION**

## Allowable Subject Matter

- 1. Claims 10-14 allowed.
- 2. Claims 4-7 objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

# Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. Claims 1-3, 8 and 9 rejected under 35 U.S.C. 103(a) as being unpatentable over Mandelman et al. (2002/0085434) in view of Mandelman et al. (6,440,872) further in view of Benedict et al. (6,046,487).

Regarding Claims 1-3, 8 and 9, Mandelman et al. disclose a structure and process for 6F2 trench capacitor DRAM cell with vertical MOSFET and 3F bitline pitch where in claims section it is disclosed a DRAM cell with a deep trench with bottom and sidewalls in the semiconductor substrate, a storage capacitor at the bottom of the deep trench, a gate conductor extending within the deep trench, isolation extending down at least one sidewall of the deep trench. In Claim 33, it is disclosed the liner. Mandelman et al. (2002/0085434) fail to disclose the required liner in the required configuration and the required liner composition. However, Mandelman et al. (6,440,872) disclose a method

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for hybrid DRAM cell utilizing confined strap isolation where in Fig. 7B, layers 30 and 42 are the SiN liner. Furthermore, Benedict et al. disclose a shallow trench isolation with oxide-nitride/oxynitride liner where the required nitride compound liner is disclosed.

It would have been obvious to one of having ordinary skill in the art at the time the invention was made to include the required liner configuration and the liner composition in Mandelman et al. ('434) as taught by Mandelman et al. ('872) and Benedict et al. in order to have a DRAM cell structure with increased performance.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Fazli Erdem whose telephone number is (571) 272-1914. The examiner can normally be reached on M - F 8:00 - 5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nathan Flynn can be reached on (571) 272-1915. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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September 17, 2004

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800